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(54) Title: LOW-TEMPERATURE CURABLE NEGATIVE TYPE PHOTSENSITIVE COMPOSITION

(57) Abstract: To provide a negative type photosensitive composition having excellent chemical resistance and capable of being cured at a low temperature. A negative type photosensitive composition comprising (I) a polysiloxane having a specific structure, (II) a polymerization initiator, (III) a compound containing two or more (meth)acryloyloxy groups, and (IV) a solvent.



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